

Notice of References CitedApplication/Control No.
09/606,040Applicant(s)/Patent Under
Reexamination
SIGRIST ET AL.Examiner
Fariba GhashghaeeArt Unit
1656

Page 1 of 1

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*		Document Number	Date	Name	Classification	
		Country Code-Number-Kind Code	MM-YYYY			
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*	C	US-5,858,802	01-1999	Chai-Gao et al.	436	524
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	K	US-				
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*	N	WO 96/31557	10-1996	WO	Jacobsen et al.	C08J	7/18
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Leonard et al. ("ToF-SIMS and XPS Study of Photoactivatable Reagents Designed for Surface Glycoengineering", Surface and Interface Analysis, 26, pp. 793-799, 1998).
	V	Chevolot et al. ("Synthesis and Characterization of a Photoactivatable Glycoaryldiazirine for Surface Glycoengineering", Bioconjugate Chem. 10, pp. 169-175, 1998).
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.